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6,6-Dimethyl-2*H*,5*H*,6*H*,7*H*-1,3-dithiolo[4,5-*f*][1,5,3]dithiasilepin-2-oneHongqi Li,^{a*} Xuebin Zhang,^a Zhongbao Zhang,^a Zhen Chen^a and Jiajian Peng^b

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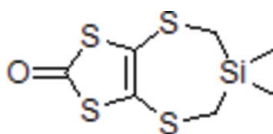
Received 28 February 2012; accepted 14 March 2012

Key indicators: single-crystal X-ray study; $T = 296$ K; mean $\sigma(\text{C}-\text{C}) = 0.004$ Å; R factor = 0.031; wR factor = 0.072; data-to-parameter ratio = 16.8.

In the structure of the title compound, $\text{C}_7\text{H}_{10}\text{OS}_4\text{Si}$, the carbonyl O atom lies in the plane of the five-membered dithiole ring with a deviation of only 0.022 (2) Å. The seven-membered ring adopts a chair conformation. The crystal packing is stabilized by $\text{S}\cdots\text{O}$ [3.096 (4) Å] and $\text{S}\cdots\text{S}$ [3.620 (4) Å] contacts, together with $\text{C}-\text{H}\cdots\text{S}$ interactions.

Related literature

For silicon-containing tetrathiafulvalene (TTF) derivatives as ligands, see: Guyon *et al.* (2005), and as precursors for the construction of polymetallic arrays, see: Hameau *et al.* (2008). For their use in the preparation of conducting charge-transfer complexes and radical-cation salts, see: Biaso *et al.* (2007). For the synthesis, see: Li *et al.* (2012). For related structures, see: Arumugam *et al.* (2011); Hou *et al.* (2009).



Experimental

Crystal data

$\text{C}_7\text{H}_{10}\text{OS}_4\text{Si}$
 $M_r = 266.48$

Triclinic, $P\bar{1}$
 $a = 6.148$ (7) Å

$b = 8.569$ (10) Å
 $c = 11.846$ (14) Å
 $\alpha = 69.292$ (12)°
 $\beta = 85.821$ (13)°
 $\gamma = 83.129$ (13)°
 $V = 579.2$ (12) Å³

$Z = 2$
Mo $K\alpha$ radiation
 $\mu = 0.88$ mm⁻¹
 $T = 296$ K
 $0.12 \times 0.10 \times 0.08$ mm

Data collection

Bruker APEXII CCD diffractometer
Absorption correction: multi-scan (SADABS; Sheldrick, 2004)
 $T_{\min} = 0.901$, $T_{\max} = 0.933$

4000 measured reflections
2012 independent reflections
1628 reflections with $I > 2\sigma(I)$
 $R_{\text{int}} = 0.019$

Refinement

$R[F^2 > 2\sigma(F^2)] = 0.031$
 $wR(F^2) = 0.072$
 $S = 1.01$
2012 reflections

120 parameters
H-atom parameters constrained
 $\Delta\rho_{\text{max}} = 0.25$ e Å⁻³
 $\Delta\rho_{\text{min}} = -0.26$ e Å⁻³

Table 1

Hydrogen-bond geometry (Å, °).

$D-H\cdots A$	$D-H$	$H\cdots A$	$D\cdots A$	$D-H\cdots A$
$\text{C5}-\text{H5B}\cdots\text{S1}^i$	0.97	2.89	3.673 (5)	138

Symmetry code: (i) $-x + 2, -y + 1, -z + 1$.

Data collection: APEX2 (Bruker, 2004); cell refinement: SAINT (Bruker, 2004); data reduction: SAINT; program(s) used to solve structure: SHELXS97 (Sheldrick, 2008); program(s) used to refine structure: SHELXL97 (Sheldrick, 2008); molecular graphics: SHELXTL; software used to prepare material for publication: SHELXTL.

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Supplementary data and figures for this paper are available from the IUCr electronic archives (Reference: SJ5206).

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supporting information

Acta Cryst. (2012). E68, o1122 [https://doi.org/10.1107/S1600536812011142]

6,6-Dimethyl-2*H*,5*H*,6*H*,7*H*-1,3-dithiolo[4,5-*f*][1,5,3]dithiasilepin-2-one**Hongqi Li, Xuebin Zhang, Zhongbao Zhang, Zhen Chen and Jiajian Peng****S1. Comment**

Silicon-containing tetrathiafulvalene (TTF) derivatives have been synthesized and used as novel assembling ligands for the construction of bimetallic transition metal complexes (Guyon *et al.*, 2005), as very promising precursors for the construction of polymetallic arrays (Hameau *et al.*, 2008), or for the preparation of conducting charge transfer complexes and radical-cation salts (Biaso *et al.*, 2007). 4,5-(2,2-Dimethyl-2-silapropylene)dithio-1,3-dithiole-2-one is useful in the synthesis of new silyl-substituted TTF derivatives. Its single crystal structure has not been reported yet, though crystal structures of analogous 1,3-dithiole-2-one and 1,3-dithiole-2-thione compounds have been studied (Arumugam *et al.*, 2011; Hou *et al.*, 2009). Herein we present the single crystal structure of the title compound.

In the title compound the carbonyl-oxygen atom (O1) lies in the plane of the five-membered dithiole ring (C1-C3/S1/S2/O1) with a deviation of only -0.022 (2) Å. The seven-membered ring adopts a chair conformation. Crystal packing is characterized by intermolecular S...O interaction with S1...O1 distance of 3.096 (4) Å and S...S contacts at 3.620 (4) Å. In addition, short intermolecular C—H...S contacts are also observed (Table 1).

S2. Experimental

The title compound was prepared as reported in the literature (Li *et al.*, 2012). Single crystals suitable for X-ray diffraction measurement was obtained by slow evaporation from a solution of petroleum ether and ethyl acetate (1:1).

S3. Refinement

All H atoms were placed at calculated positions and refined using a riding model approximation, with C—H = 0.96 or 0.97 Å and with $U_{\text{iso}}(\text{H}) = 1.2U_{\text{eq}}(\text{C})$ or $1.5U_{\text{eq}}(\text{C})$ for methyl H atoms.

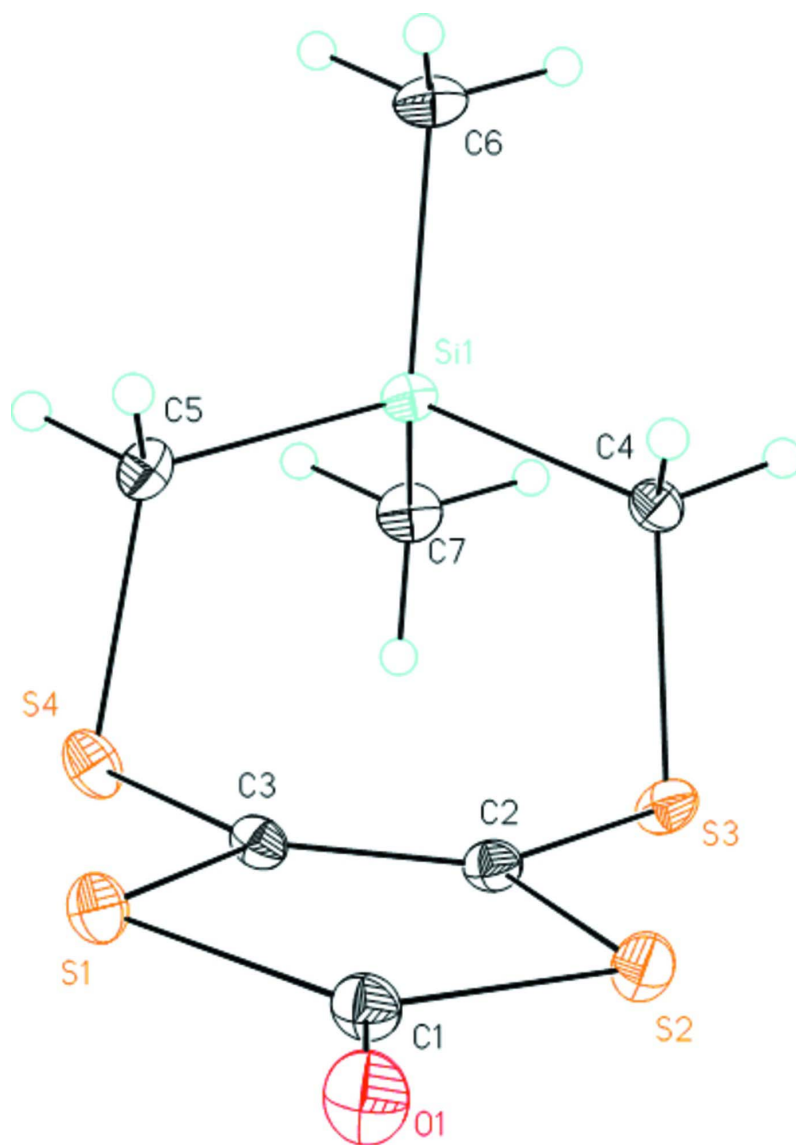


Figure 1

A view of the molecule of the title compound. Displacement ellipsoids are drawn at the 30% probability level and H atoms are shown as small spheres of arbitrary radii.

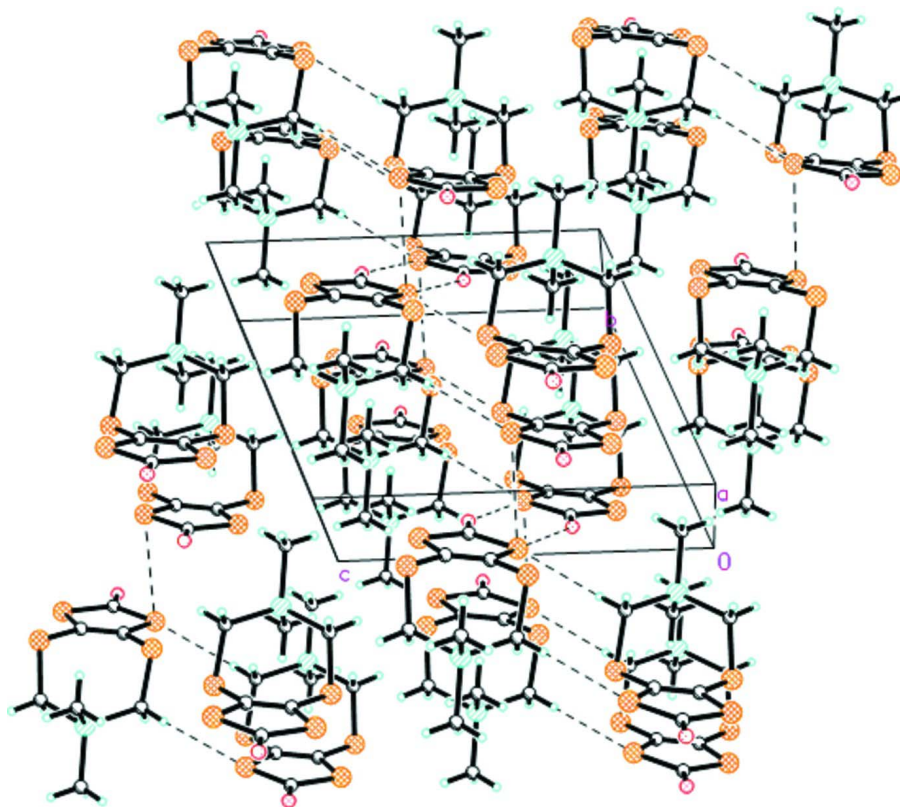


Figure 2

The crystal structure of the title compound, viewed along *a* axis

6,6-Dimethyl-2*H*,5*H*,6*H*,7*H*-1,3- dithiolo[4,5-*f*][1,5,3]dithiasilepin-2-one

Crystal data

$C_7H_{10}OS_4Si$

$M_r = 266.48$

Triclinic, $P\bar{1}$

Hall symbol: -P 1

$a = 6.148 (7) \text{ \AA}$

$b = 8.569 (10) \text{ \AA}$

$c = 11.846 (14) \text{ \AA}$

$\alpha = 69.292 (12)^\circ$

$\beta = 85.821 (13)^\circ$

$\gamma = 83.129 (13)^\circ$

$V = 579.2 (12) \text{ \AA}^3$

$Z = 2$

$F(000) = 276$

$D_x = 1.528 \text{ Mg m}^{-3}$

Melting point = 325–326 K

Mo $K\alpha$ radiation, $\lambda = 0.71073 \text{ \AA}$

Cell parameters from 1863 reflections

$\theta = 2.6\text{--}27.4^\circ$

$\mu = 0.88 \text{ mm}^{-1}$

$T = 296 \text{ K}$

Block, colorless

$0.12 \times 0.10 \times 0.08 \text{ mm}$

Data collection

Bruker APEXII CCD

diffractometer

Radiation source: fine-focus sealed tube

Graphite monochromator

φ and ω scans

Absorption correction: multi-scan

(*SADABS*; Sheldrick, 2004)

$T_{\min} = 0.901$, $T_{\max} = 0.933$

4000 measured reflections

2012 independent reflections

1628 reflections with $I > 2\sigma(I)$

$R_{\text{int}} = 0.019$

$\theta_{\max} = 25.0^\circ$, $\theta_{\min} = 2.6^\circ$

$h = -7 \rightarrow 7$

$k = -10 \rightarrow 10$

$l = -14 \rightarrow 12$

*Refinement*Refinement on F^2

Least-squares matrix: full

 $R[F^2 > 2\sigma(F^2)] = 0.031$ $wR(F^2) = 0.072$ $S = 1.01$

2012 reflections

120 parameters

0 restraints

Primary atom site location: structure-invariant
direct methodsSecondary atom site location: difference Fourier
mapHydrogen site location: inferred from
neighbouring sites

H-atom parameters constrained

 $w = 1/[\sigma^2(F_o^2) + (0.027P)^2 + 0.3021P]$ where $P = (F_o^2 + 2F_c^2)/3$ $(\Delta/\sigma)_{\max} = 0.001$ $\Delta\rho_{\max} = 0.25 \text{ e } \text{Å}^{-3}$ $\Delta\rho_{\min} = -0.26 \text{ e } \text{Å}^{-3}$ *Special details*

Geometry. All e.s.d.'s (except the e.s.d. in the dihedral angle between two l.s. planes) are estimated using the full covariance matrix. The cell e.s.d.'s are taken into account individually in the estimation of e.s.d.'s in distances, angles and torsion angles; correlations between e.s.d.'s in cell parameters are only used when they are defined by crystal symmetry. An approximate (isotropic) treatment of cell e.s.d.'s is used for estimating e.s.d.'s involving l.s. planes.

Refinement. Refinement of F^2 against ALL reflections. The weighted R -factor wR and goodness of fit S are based on F^2 , conventional R -factors R are based on F , with F set to zero for negative F^2 . The threshold expression of $F^2 > \sigma(F^2)$ is used only for calculating R -factors(gt) *etc.* and is not relevant to the choice of reflections for refinement. R -factors based on F^2 are statistically about twice as large as those based on F , and R -factors based on ALL data will be even larger.

Fractional atomic coordinates and isotropic or equivalent isotropic displacement parameters (Å^2)

	x	y	z	$U_{\text{iso}}^*/U_{\text{eq}}$
C1	1.2928 (4)	0.0788 (3)	0.3530 (2)	0.0504 (7)
C2	0.9211 (4)	0.2483 (3)	0.2614 (2)	0.0417 (6)
C3	0.9299 (4)	0.2691 (3)	0.3675 (2)	0.0406 (6)
C4	0.7687 (4)	0.5515 (3)	0.0965 (2)	0.0439 (6)
H4A	0.7085	0.6027	0.0167	0.053*
H4B	0.9260	0.5568	0.0873	0.053*
C5	0.7677 (4)	0.5943 (3)	0.3452 (2)	0.0476 (7)
H5A	0.9237	0.6060	0.3372	0.057*
H5B	0.7013	0.6636	0.3904	0.057*
C6	0.7323 (5)	0.8941 (3)	0.1163 (3)	0.0650 (8)
H6A	0.6818	0.9381	0.0351	0.097*
H6B	0.8890	0.8919	0.1147	0.097*
H6C	0.6672	0.9640	0.1601	0.097*
C7	0.3523 (4)	0.6708 (4)	0.2051 (3)	0.0597 (8)
H7A	0.2889	0.7372	0.2519	0.090*
H7B	0.3200	0.5568	0.2443	0.090*
H7C	0.2920	0.7145	0.1261	0.090*
O1	1.4633 (3)	-0.0091 (3)	0.37000 (19)	0.0718 (6)
S1	1.16208 (11)	0.17662 (9)	0.45212 (6)	0.0500 (2)
S2	1.14230 (12)	0.12822 (9)	0.22118 (7)	0.0539 (2)
S3	0.71611 (11)	0.33291 (8)	0.15538 (7)	0.0519 (2)
S4	0.72980 (11)	0.37770 (10)	0.43285 (6)	0.0561 (2)
Si1	0.65327 (11)	0.67844 (9)	0.19121 (7)	0.04113 (19)

Atomic displacement parameters (\AA^2)

	U^{11}	U^{22}	U^{33}	U^{12}	U^{13}	U^{23}
C1	0.0479 (16)	0.0476 (16)	0.0509 (17)	0.0014 (13)	-0.0094 (13)	-0.0116 (13)
C2	0.0408 (14)	0.0361 (14)	0.0462 (15)	-0.0036 (11)	-0.0095 (11)	-0.0106 (12)
C3	0.0349 (13)	0.0416 (14)	0.0396 (14)	-0.0054 (11)	-0.0040 (11)	-0.0063 (12)
C4	0.0450 (15)	0.0410 (15)	0.0408 (15)	0.0001 (11)	-0.0060 (12)	-0.0085 (12)
C5	0.0355 (13)	0.0572 (17)	0.0579 (17)	-0.0006 (12)	0.0021 (12)	-0.0317 (14)
C6	0.0622 (19)	0.0425 (16)	0.087 (2)	-0.0083 (14)	0.0008 (17)	-0.0189 (16)
C7	0.0345 (14)	0.0643 (19)	0.078 (2)	0.0007 (13)	-0.0026 (14)	-0.0239 (17)
O1	0.0599 (13)	0.0760 (15)	0.0739 (15)	0.0266 (11)	-0.0219 (11)	-0.0261 (12)
S1	0.0450 (4)	0.0574 (4)	0.0450 (4)	0.0013 (3)	-0.0140 (3)	-0.0141 (3)
S2	0.0602 (4)	0.0494 (4)	0.0527 (4)	0.0113 (3)	-0.0155 (3)	-0.0214 (3)
S3	0.0549 (4)	0.0422 (4)	0.0610 (5)	-0.0007 (3)	-0.0273 (3)	-0.0176 (3)
S4	0.0457 (4)	0.0701 (5)	0.0429 (4)	0.0004 (3)	0.0075 (3)	-0.0114 (4)
Si1	0.0305 (3)	0.0406 (4)	0.0525 (4)	-0.0031 (3)	0.0015 (3)	-0.0171 (3)

Geometric parameters (\AA , $^\circ$)

C1—O1	1.200 (3)	C5—S4	1.812 (3)
C1—S1	1.768 (3)	C5—Si1	1.865 (3)
C1—S2	1.767 (3)	C5—H5A	0.9700
C2—C3	1.336 (4)	C5—H5B	0.9700
C2—S2	1.747 (3)	C6—Si1	1.852 (3)
C2—S3	1.749 (3)	C6—H6A	0.9600
C3—S1	1.746 (3)	C6—H6B	0.9600
C3—S4	1.753 (3)	C6—H6C	0.9600
C4—S3	1.813 (3)	C7—Si1	1.853 (3)
C4—Si1	1.873 (3)	C7—H7A	0.9600
C4—H4A	0.9700	C7—H7B	0.9600
C4—H4B	0.9700	C7—H7C	0.9600
O1—C1—S1	125.6 (2)	Si1—C6—H6B	109.5
O1—C1—S2	122.9 (2)	H6A—C6—H6B	109.5
S1—C1—S2	111.47 (17)	Si1—C6—H6C	109.5
C3—C2—S2	116.77 (19)	H6A—C6—H6C	109.5
C3—C2—S3	127.3 (2)	H6B—C6—H6C	109.5
S2—C2—S3	115.90 (16)	Si1—C7—H7A	109.5
C2—C3—S1	117.2 (2)	Si1—C7—H7B	109.5
C2—C3—S4	126.9 (2)	H7A—C7—H7B	109.5
S1—C3—S4	115.92 (16)	Si1—C7—H7C	109.5
S3—C4—Si1	115.17 (15)	H7A—C7—H7C	109.5
S3—C4—H4A	108.5	H7B—C7—H7C	109.5
Si1—C4—H4A	108.5	C3—S1—C1	97.14 (15)
S3—C4—H4B	108.5	C2—S2—C1	97.32 (14)
Si1—C4—H4B	108.5	C2—S3—C4	100.85 (12)
H4A—C4—H4B	107.5	C3—S4—C5	102.02 (14)
S4—C5—Si1	116.21 (14)	C6—Si1—C7	112.72 (14)

S4—C5—H5A	108.2	C6—Si1—C5	107.85 (14)
Si1—C5—H5A	108.2	C7—Si1—C5	108.97 (14)
S4—C5—H5B	108.2	C6—Si1—C4	107.65 (15)
Si1—C5—H5B	108.2	C7—Si1—C4	107.94 (13)
H5A—C5—H5B	107.4	C5—Si1—C4	111.76 (14)
Si1—C6—H6A	109.5		

Hydrogen-bond geometry (Å, °)

<i>D</i> —H \cdots <i>A</i>	<i>D</i> —H	H \cdots <i>A</i>	<i>D</i> \cdots <i>A</i>	<i>D</i> —H \cdots <i>A</i>
C5—H5B \cdots Si1 ⁱ	0.97	2.89	3.673 (5)	138

Symmetry code: (i) $-x+2, -y+1, -z+1$.